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UV AND VUV DEGRADATION OF VERY HIGH REFLECTIVITY
MIRRORS FOR USE IN A STO. (U) STANFORD UNIV CA HIGH
ENERGY PHYSICS LAB P ELLEAUME ET AL. MAY 83 HEPL-922
UNCLASSIFIED AFDSR-TR-84-0105 F49620-80-C-0068 F/G 20/6

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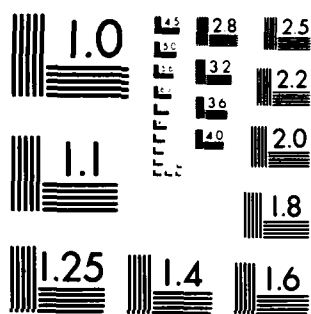
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REPORT DOCUMENTATION PAGE		READ INSTRUCTIONS BEFORE COMPLETING FORM
1. REPORT NUMBER AFOSR-TR-84-0105	2. GOVT ACCESSION NO. AD-A138740	3. RECIPIENT'S CATALOG NUMBER
4. TITLE and Subtitle UV AND VUV DEGRADATION OF VERY HIGH REFLECTIVITY MIRRORS FOR USE IN A STORAGE RING FREE ELECTRON LASER		5. TYPE OF REPORT & PERIOD COVERED INTERIM
7. AUTHOR(s) P. ELLEAUME, D.A.G. DEACON, M. BILLARDON, J.M. ORTEGA		6. PERFORMING ORG. REPORT NUMBER
9. PERFORMING ORGANIZATION NAME AND ADDRESS STANFORD UNIVERSITY STANFORD, CA 94305		8. CONTRACT OR GRANT NUMBER(s) F49620-80-C-0068
11. CONTROLLING OFFICE NAME AND ADDRESS AFOSR/NP Bolling AFB, DC 20332		10. PROGRAM ELEMENT, PROJECT, TASK AREA & WORK UNIT NUMBERS 61102F 2301/A1
14. MONITORING AGENCY NAME & ADDRESS (if different from Controlling Office)		12. REPORT DATE MAY 1983
		13. NUMBER OF PAGES 6
		15. SECURITY CLASS. (of this report) UNCLASSIFIED
		15a. DECLASSIFICATION DOWNGRADING SCHEDULE
16. DISTRIBUTION STATEMENT (of this Report) APPROVED FOR PUBLIC RELEASE; DISTRIBUTION UNLIMITED.		
17. DISTRIBUTION STATEMENT (of the abstract entered in Block 20, if different from Report)		
18. SUPPLEMENTARY NOTES to be presented at CLEO '83, Baltimore, MD, MAY 1983		
19. KEY WORDS (Continue on reverse side if necessary and identify by block number)		
20. ABSTRACT (Continue on reverse side if necessary and identify by block number) TiO ₂ /SiO ₂ multilayer dielectric mirrors centered around 630 nm have shown reflectivity degradation from 99.99% down to 99.0% due to UV synchrotron radiation emitted by a beam of 240 MeV electrons during a storage ring free electron laser experiment.		

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AFOSR-TR- 84 - 0 1 0 5

(To be presented at CLEO '83
Baltimore, Maryland, May 1983)

HEPL 922

FEBRUARY 1983

UV AND VUV DEGRADATION OF VERY HIGH REFLECTIVITY MIRRORS
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Introduction :

The Orsay free electron laser (FEL) has a round trip gain on the order of several 10^{-4} [1] due to the limited straight section length available on the ACO storage ring and to the available electron density. The oscillation experiment requires the use of extraordinarily low loss mirrors. Much experience exists in the fabrication and measurement of $\text{TiO}_2/\text{SiO}_2$ multilayer dielectric mirrors, and the reflectivity which has been obtained at 630 nm ($R = 99.99\%$) is sufficient for oscillation of the FEL. To insure minimum cavity losses (high cavity Q), the mirrors are placed, without windows, in the ultra-high vacuum of the storage ring. Here they have to withstand the strong UV and VUV undulator radiation [2] emitted by a typical current of 100 mA of 150 MeV to 240 MeV electrons.

The Q of the cavity was monitored using two techniques. Both of them measure the cavity decay time of light either emitted from inside the cavity (undulator radiation [1]) or from an external laser [3]. The last method has a signal to noise ratio $\sim 5\%$ and allows reflectivity measurement before insertion into the vacuum and after extraction at the end of the experiment.

Mirror degradation :

The mirror degradation data are summarized in the following table :

Mirror Batch Code	A δ	2 α	B ϵ	B γ
Loss/mirror in air	$1.3 \cdot 10^{-4}$	$4.5 \cdot 10^{-4}$	$.8 \cdot 10^{-4}$	
Loss/mirror after 10^{-10} Torr pump down	$8.5 \cdot 10^{-4}$	$9.9 \cdot 10^{-4}$	$3.5 \cdot 10^{-4}$	
Average degradation rate/mirror/100 mA electron current/hour		$3.2 \cdot 10^{-4}$	$0.1 \cdot 10^{-4}$	$20 \cdot 10^{-4}$
Electron energy (MeV)		238	150	230
Undulator flux at fundamental (1.9 eV) (photons/sec/cm ² /mA)	No precise data	$6.8 \cdot 10^{14}$	$3.1 \cdot 10^{14}$	$5.6 \cdot 10^{14}$
Flux at 3rd harmonic (5.7 eV)		$3.2 \cdot 10^{14}$	$3.7 \cdot 10^{13}$	$2.9 \cdot 10^{14}$
Flux at 5th harmonic (9.5 eV)		$1.7 \cdot 10^{14}$	$5.0 \cdot 10^{12}$	$1.8 \cdot 10^{14}$

Two different degradation mechanisms are identified. The first occurs during the process of pumping down to 10^{-10} Torr but before any light exposure. This process is not yet understood, but is too strong to be explained by the bulk index contribution of water desorbed from the coating layers. Without any synchrotron light exposure, the mirror reflectivity was stable within a precision of 10^{-5} during a 12 hour measurement period and was unchanged after a 75 Roentgen exposure to X ray and gamma radiation generated during the storage ring injection. The second degradation process occurs systematically during light exposure. Since there is no shift in the transmission curve of the mirrors before and after exposure either in wavelength or in magnitude, we conclude that the mirror degradation occurs in either the absorption or the scattering channels. The emission spectrum from an undulator has peaks at each harmonic of the fundamental photon energy (1.9 eV in our case) [2]. The flux in each harmonic depends on the energy (see the table). The increase in the B γ degradation rate by a factor of more than twenty from 150 MeV proves that most of the degradation comes from harmonics greater than the 3rd (photon

Discussion :

Mirror degradation is a serious problem for the ACO FEL because of the low gain. Similar degradation has been found for the Novosibirsk FEL [4]. The new generation of storage rings optimized for synchrotron radiation (Aladdin, Bessy, Brookhaven, Super ACO) should give optical gains on the order of several percent, but their UV fluxes will be significantly higher than on ACO. The solution to the problem may lie in the selection of UV resistant materials for the mirrors, or in a shielding technique with an intracavity Brewster plate or a vapor deposited UV absorber on the mirror surface. We plan to investigate some of these possibilities on the ACO system, but the dimensions of the problem would appear to necessitate a systematic effort if it is to be resolved.

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AFOSR contract # - F49620-80-C-0068